Development of High-performance Purfluorinated Polymer Electret

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I. INTRODUCTION

Recently, micro power generation using electret-based electrostatic induction attracts much attention due to its large power output at low frequency range [1, 2]. Since theoretical power output is proportional to the square of the surface charge density of electret, development of high-performance electret is required. Boland et al. [1] employed Teflon[®] AF (Du Pont) as their electret film. We previously found that perfluorinated polymer CYTOPTM CTL-M (Asahi Glass Co., Ltd.) shows high surface charge density of 1.3 mC/m² (at the thickness of 16 μ m), which is 3 times larger than that of Teflon AF [2]. This paper presents a new high-performance polymer electret with higher surface charge density, stability, and high thermal resistibility of electric charges.

II. HIGH PREFORMANCE POLYMER ELECTRET

A. High Surface Charge DensityPolymer Electret

Figure 1 shows the molecular structure of CYTOP. There are three different types of commercial grade CYTOP depending upon their end group, i.e., trifluoromethyl (CTL-S), carboxyl (CTL-A), and amidosilyl (CTL-M). Corona discharge is employed for the charging, and a series of measurements of surface potential was made.

We found that the functional end group, especially amidosilyl in CTL-M, significantly enhances the surface charge density of CYTOP. Thus, we doped aminosilane into the CTL-A to increase the concentration of amidosilyl functional group. Figure 2 shows the surface charge density of 15 μ m-thick electret film for different concentration of aminosilane. By doping only 0.6-3.0% of aminosilane into CTL-A, the surface charge density has been doubled; surface charge density as high as 1.5 mC/m² has been achieved, and it remains constant over 4000 hours.



Fig. 1. The molecular structure and the end groups of CYTOP.

B. Thermal Property of Aminosilane-doped Perfluoropolymer Figure 3 shows the TSD spectra of aminosilane-doped CTL-

A in comparison with that of CTL-A and CTL-M. The peak



Fig. 2. Time trace of the surface charge density of aminosilane-doped CYTOP (aminosilane 0.6 wt%, and 3.0 wt%; film thickness:15µm)



Fig. 3. TSD spectra of CTL-A, CTL-M, and aminosilane-doped CYTOP (aminosilane 3.0 wt%; film thickness:15µm)

temperature of TSD spectra of aminosilane-doped CTL-A is shifted to much higher temperature of 184°C.

In summary, both surface charge density and thermal stability are improved by doping of aminosilane into CYTOP. The charge density of 1.5 mC/cm², which is 3.5 times larger than that of Teflon AF, has been obtained on 15 μ m-thick film.

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